



**IN THE UNITED STATES PATENT AND TRADEMARK OFFICE**

<u>In re application of:</u> Cyril Cabral, Jr.	<u>Filed:</u> 11/21/2003
	<u>Examiner:</u> Kiesha L. Rose
<u>Serial No.</u> 10/707,117	<u>Group Art Unit:</u> 2822
<u>Title:</u> Interconnect Structure Diffusion Barrier With High Nitrogen Content	<u>Docket #:</u> FIS920030252US1

**AMENDMENT**

Commissioner of Patents & Trademarks  
Alexandria, VA 22313

Sir:

Responsive to the Office Action of 06/14/2005, please amend the above identified  
application as follows: